

Suns-Voc MX: Post-Diffusion Process Control



The Suns-Voc MX stage is available as an accessory to the WCT-120 lifetime testing instrument or as a stand-alone measurement system.

Perfect for paste-firing optimization and process control.

Open-circuit method indicates the upper bound for any solar cell precursors after junction formation.

Product Overview

The Suns-Voc MX stage is ideal for measuring wafers after Al firing, and then again after front-grid firing. This allows the optimization and monitoring of these steps to maintain voltage, obtain good ohmic contacts, and avoid shunting.

Suns-Voc MX Applications

By either probing the p+ and n+ regions directly or probing the metallization layer (if present), the illumination-Voc curve can be measured. This curve can be displayed as our well-known Suns-Voc plot or in the form of a standard photovoltaic curve which can be used to characterize shunting. The entire curve is measured at open circuit, so it is free from the effects of series resistance.

Pseudo Light I-V Curve Without the Effect of Rs

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Suns-Voc data displayed in the form of an illuminated I-V curve.

Comparing this curve to the final I-V curve gives a precise measure of the series resistance in the cell.

Suns-Voc MX System Features

- Wafer chuck controlled at 25°C
- · Fine-point voltage probe
- Upgraded 3-configuration magnetic probe bar included
- Xenon flashlamp with set of neutral-density filters
- Height-adjustable flash for fine-tuning intensity range
- Displays standard I-V curve format as well as the Suns-Voc curve
- Measures ideal wafer characteristics without the effects of series resistance
- Measures effective lifetime characteristic curve
- · Measures substrate doping

Suns-Voc MX Specifications

Instrument Specifications

Parameters reported for each measurement

- Implied I-V curve at open circuit: materials limit to efficiency
- Pseudo-efficiency
- · Pseudo-fill-factor
- Double-diode analysis
- Shunt value
- Effective lifetime vs. carrier density
- Inverse lifetime vs. carrier density and Joe
- · Substrate doping

Typical calibrated illumination range

• 0.006-6 suns

Wafer size, standard configuration

• Maximum 240-mm diameter/side

Warranty

• One-year limited warranty on all parts and software



Facility Requirements

Chuck temperature control

25°C

Ambient operating temperature

• 18°C-25°C

Power requirements

- Computer with monitor: 200 W
- · Light source: 60 W

Dimensions

• 32 cm W x 28.5 cm D x 75 cm H

Universal mains voltage

• 100-240 VAC 50/60 Hz

Special facilities requirements None

Purchasing Information

For a quote, please contact quotes@sintoninstruments.com.

We are happy to accommodate custom requirements. Please inquire about a quote for your specific needs.

Quotes are valid for 60 days.

For our full product line, visit our website at: www.sintoninstruments.com

